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(54) **Title:** INTERGRATED TOUCH SCREEN FOR INTERFEROMETRIC MODULATOR DISPLAY.

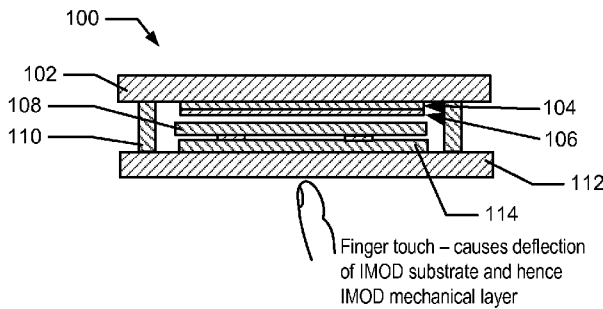


FIG. 8A

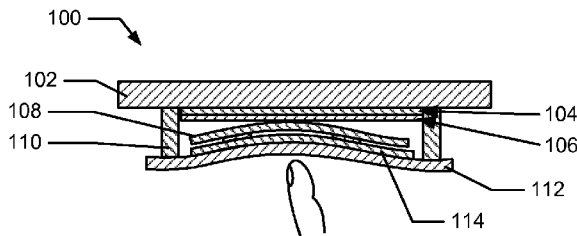


FIG. 8B

(57) **Abstract:** An interferometric modulator ("IMOD") display utilizes ambient light and incorporates touch sensing without reducing the amount of ambient light that reaches the MEMS modulators, and without introducing any optical distortion or loss of performance. Electrodes for touch sensing are located at a back glass of the interferometric display, and are used in conjunction with electrodes whose primary function is to activate the pixels of the MEMS display, in order to sense a touch. The touch deflects the IMOD layers and is sensed through the various display layers at the rear of the display.

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INTERGRATED TOUCH SCREEN FOR INTERFEROMETRIC MODULATOR DISPLAY.

### **PRIORITY CLAIM**

[0001] This application claims priority to United States Patent Application No. 12/645,379,  
5 entitled "INTEGRATED TOUCH FOR IMOD DISPLAYS USING BACK GLASS" and  
filed on December 22, 2009, which is hereby incorporated by reference and for all purposes.

### **BACKGROUND OF THE INVENTION**

#### **Description of Related Technology**

[0002] Microelectromechanical systems (MEMS) include micro mechanical elements,  
10 actuators, and electronics. Micromechanical elements may be created using deposition,  
etching, and or other micromachining processes that etch away parts of substrates and/or  
deposited material layers or that add layers to form electrical and electromechanical devices.  
One type of MEMS device is called an interferometric modulator. As used herein, the term  
interferometric modulator or interferometric light modulator refers to a device that selectively  
15 absorbs and/or reflects light using the principles of optical interference. In certain  
embodiments, an interferometric modulator may comprise a pair of conductive plates, one or  
both of which may be transparent and/or reflective in whole or part and capable of relative  
motion upon application of an appropriate electrical signal. In a particular embodiment, one  
plate may comprise a stationary layer deposited on a substrate and the other plate may  
20 comprise a metallic membrane separated from the stationary layer by an air gap. As  
described herein in more detail, the position of one plate in relation to another can change  
the optical interference of light incident on the interferometric modulator. Such devices have  
a wide range of applications, and it would be beneficial in the art to utilize and/or modify the  
characteristics of these types of devices so that their features can be exploited in improving  
25 existing products and creating new products that have not yet been developed.

### **SUMMARY OF THE INVENTION**

[0003] An interferometric modulator ("IMOD") display utilizes ambient light and  
30 incorporates touch sensing without reducing the amount of ambient light and creating any  
optical distortion or loss of performance. Electrodes for touch sensing are located at a rear

substrate or “back glass” of the interferometric display, and are used in conjunction with electrodes whose primary function is to activate the pixels of the MEMS display, in order to sense a touch. The touch deflects the IMOD layers and is sensed through the various display layers at the rear of the display.

5 [0004] One aspect relates to a method of making and operating an interferometric display apparatus. The method comprises: providing a front substrate at a front of the display, the front substrate being substantially transparent; providing a rear substrate at a rear of the display, the rear substrate being substantially transparent; and providing an array of interferometric modulation elements disposed between the front and rear substrates. The array is disposed on the front substrate at the front of the display, and the interferometric modulation elements comprise two walls that define a cavity, one of the walls being movable relative to the other through a range of positions, the walls causing the cavity to operate interferometrically in at least one of the positions, producing a predetermined optical response to visible light. The method further comprises providing a first plurality of electrodes oriented along a first axis and configured for conducting electrical signals to the array of interferometric modulation elements, the first plurality of electrodes in contact with the rear substrate; providing a second plurality of electrodes oriented along a second axis substantially orthogonal to the first axis; utilizing one or both of the first or second plurality of electrodes as plates of a touch screen, and sensing a change in a parameter generated by a touch at the intersection between the electrodes of the first and second plurality.

[0005] In certain embodiments, the parameter comprises a capacitance value and the method further comprises computing a centroid of a capacitance change. The method may also further comprise referencing a stored map of centroid capacitance change vs. intersection data and determining the location of the touch.

25 [0006] Another aspect relates to an apparatus, comprising: a first substantially transparent substrate; and an array of interferometric modulation elements disposed on the first substantially transparent substrate, the interferometric modulation elements comprising two walls that define a cavity, one of the walls being movable relative to the other through a range of positions, the walls causing the cavity to operate interferometrically in at least one of the positions, producing a predetermined optical response to visible light. The apparatus further comprises a first plurality of electrodes configured for conducting electrical signals to the array of interferometric modulation elements; first control circuitry configured to apply

electrical signals for controlling the array of interferometric modulation elements via the first plurality of electrodes; a second substrate; a second plurality of electrodes disposed on the second substrate; and second control circuitry configured to detect capacitance changes between the first plurality of electrodes and the second plurality of electrodes and to  
5 determine a deflected area of the first substantially transparent substrate based, at least in part, on the capacitance changes.

[0007] A further understanding of the nature and advantages of the present invention may be realized by reference to the remaining portions of the specification and the drawings.

10

### **BRIEF DESCRIPTION OF THE DRAWINGS**

[0008] FIG. 1 is an isometric view depicting a portion of one embodiment of an interferometric modulator display in which a movable reflective layer of a first interferometric modulator is in a relaxed position and a movable reflective layer of a second interferometric modulator is in an actuated position.

15

[0009] FIG. 2 is a system block diagram illustrating one embodiment of an electronic device incorporating a 3x3 interferometric modulator display.

[0010] FIG. 3 is a diagram of movable mirror position versus applied voltage for one exemplary embodiment of an interferometric modulator of FIG. 1.

20

[0011] FIG. 4 is an illustration of a set of row and column voltages that may be used to drive an interferometric modulator display.

[0012] FIGS. 5A and 5B illustrate one exemplary timing diagram for row and column signals that may be used to write a frame of display data to the 3x3 interferometric modulator display of FIG. 2.

25

[0013] FIGS. 6A and 6B are system block diagrams illustrating an embodiment of a visual display device comprising a plurality of interferometric modulators.

[0014] FIG. 7A is a cross section of the device of FIG. 1.

[0015] FIG. 7B is a cross section of an alternative embodiment of an interferometric modulator.

[0016] FIG. 7C is a cross section of another alternative embodiment of an interferometric modulator.

[0017] FIG. 7D is a cross section of yet another alternative embodiment of an interferometric modulator.

5 [0018] FIG. 7E is a cross section of an additional alternative embodiment of an interferometric modulator.

[0019] FIGS. 8A, 8B, and 8C are cross sections of an additional alternative embodiment of an interferometric modulator.

[0020] FIG. 8D is a cross section of a two state embodiment of an interferometric modulator.

10 [0021] FIGS. 9A-9D are illustrations of embodiments of electrodes used in touch sensing.

[0022] FIGS. 10A and 10B are cross sections of embodiments incorporating posts in a back glass of an interferometric modulator.

[0023] FIG. 11 is a flow chart depicting an overview of device fabrication.

15 **DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS**

Interferometric Modulator

[0024] The following detailed description is directed to certain specific embodiments. However, the teachings herein can be applied in a multitude of different ways. In this  
20 description, reference is made to the drawings wherein like parts are designated with like numerals throughout. The embodiments may be implemented in any device that is configured to display an image, whether in motion (e.g., video) or stationary (e.g., still image), and whether textual or pictorial. More particularly, it is contemplated that the  
25 embodiments may be implemented in or associated with a variety of electronic devices such as, but not limited to, mobile telephones, wireless devices, personal data assistants (PDAs), hand-held or portable computers, GPS receivers/navigators, cameras, MP3 players, camcorders, game consoles, wrist watches, clocks, calculators, television monitors, flat panel displays, computer monitors, auto displays (e.g., odometer display, etc.), cockpit controls

and/or displays, display of camera views (e.g., display of a rear view camera in a vehicle), electronic photographs, electronic billboards or signs, projectors, architectural structures, packaging, and aesthetic structures (e.g., display of images on a piece of jewelry). MEMS devices of similar structure to those described herein can also be used in non-display applications such as in electronic switching devices.

[0025] An interferometric modulator (“IMOD”) display utilizes ambient light and incorporates touch sensing without reducing the amount of ambient light that reaches the MEMS modulators, and without introducing any optical distortion or loss of performance. Electrodes for touch sensing are located at a back glass of the interferometric display, and are used in conjunction with electrodes whose primary function is to activate the pixels of the MEMS display, in order to sense a touch. The touch deflects the IMOD layers and is sensed through the various display layers at the rear of the display. Embodiments of such a display are described below.

[0026] One interferometric modulator display embodiment comprising an interferometric MEMS display element is illustrated in Figure 1. In these devices, the pixels are in either a bright or dark state. In the bright (“relaxed” or “open”) state, the display element reflects a large portion of incident visible light to a user. When in the dark (“actuated” or “closed”) state, the display element reflects little incident visible light to the user. Depending on the embodiment, the light reflectance properties of the “on” and “off” states may be reversed. MEMS pixels can be configured to reflect predominantly at selected colors, allowing for a color display in addition to black and white.

[0027] Figure 1 is an isometric view depicting two adjacent pixels in a series of pixels of a visual display, wherein each pixel comprises a MEMS interferometric modulator. In some embodiments, an interferometric modulator display comprises a row/column array of these interferometric modulators. Each interferometric modulator includes a pair of reflective layers positioned at a variable and controllable distance from each other to form a resonant optical gap with at least one variable dimension. In one embodiment, one of the reflective layers may be moved between two positions. In the first position, referred to herein as the relaxed position, the movable reflective layer is positioned at a relatively large distance from a fixed partially reflective layer. In the second position, referred to herein as the actuated position, the movable reflective layer is positioned more closely adjacent to the partially reflective layer. Incident light that reflects from the two layers interferes constructively or

destructively depending on the position of the movable reflective layer, producing either an overall reflective or non-reflective state for each pixel.

[0028] The depicted portion of the pixel array in Figure 1 includes two adjacent interferometric modulators 12a and 12b. In the interferometric modulator 12a on the left, a movable reflective layer 14a is illustrated in a relaxed position at a predetermined distance from an optical stack 16a, which includes a partially reflective layer. In the interferometric modulator 12b on the right, the movable reflective layer 14b is illustrated in an actuated position adjacent to the optical stack 16b.

[0029] The optical stacks 16a and 16b (collectively referred to as optical stack 16), as referenced herein, typically comprise several fused layers, which can include an electrode layer, such as indium tin oxide (ITO), a partially reflective layer, such as chromium, and a transparent dielectric. The optical stack 16 is thus electrically conductive, partially transparent and partially reflective, and may be fabricated, for example, by depositing one or more of the above layers onto a transparent substrate 20. The partially reflective layer can be formed from a variety of materials that are partially reflective such as various metals, semiconductors, and dielectrics. The partially reflective layer can be formed of one or more layers of materials, and each of the layers can be formed of a single material or a combination of materials.

[0030] In some embodiments, the layers of the optical stack 16 are patterned into parallel strips, and may form row electrodes in a display device as described further below. The movable reflective layers 14a, 14b may be formed as a series of parallel strips of a deposited metal layer or layers (orthogonal to the row electrodes of 16a, 16b) to form columns deposited on top of posts 18 and an intervening sacrificial material deposited between the posts 18. When the sacrificial material is etched away, the movable reflective layers 14a, 14b are separated from the optical stacks 16a, 16b by a defined gap 19. A highly conductive and reflective material such as aluminum may be used for the reflective layers 14, and these strips may form column electrodes in a display device. Note that Figure 1 may not be to scale. In some embodiments, the spacing between posts 18 may be on the order of 10-100 um, while the gap 19 may be on the order of <1000 Angstroms.

[0031] With no applied voltage, the gap 19 remains between the movable reflective layer 14a and optical stack 16a, with the movable reflective layer 14a in a mechanically relaxed state,



as illustrated by the pixel 12a in Figure 1. However, when a potential (voltage) difference is applied to a selected row and column, the capacitor formed at the intersection of the row and column electrodes at the corresponding pixel becomes charged, and electrostatic forces pull the electrodes together. If the voltage is high enough, the movable reflective layer 14 is deformed and is forced against the optical stack 16. A dielectric layer (not illustrated in this Figure) within the optical stack 16 may prevent shorting and control the separation distance between layers 14 and 16, as illustrated by actuated pixel 12b on the right in Figure 1. The behavior is the same regardless of the polarity of the applied potential difference.

[0032] Figures 2 through 5 illustrate one exemplary process and system for using an array of interferometric modulators in a display application.

[0033] Figure 2 is a system block diagram illustrating one embodiment of an electronic device that may incorporate interferometric modulators. The electronic device includes a processor 21 which may be any general purpose single- or multi-chip microprocessor such as an ARM<sup>®</sup>, Pentium<sup>®</sup>, 8051, MIPS<sup>®</sup>, Power PC<sup>®</sup>, or ALPHA<sup>®</sup>, or any special purpose microprocessor such as a digital signal processor, microcontroller, or a programmable gate array. As is conventional in the art, the processor 21 may be configured to execute one or more software modules. In addition to executing an operating system, the processor may be configured to execute one or more software applications, including a web browser, a telephone application, an email program, or any other software application.

[0034] In one embodiment, the processor 21 is also configured to communicate with an array driver 22. In one embodiment, the array driver 22 includes a row driver circuit 24 and a column driver circuit 26 that provide signals to a display array or panel 30. The cross section of the array illustrated in Figure 1 is shown by the lines 1-1 in Figure 2. Note that although FIG. 2 illustrates a 3x3 array of interferometric modulators for the sake of clarity, the display array 30 may contain a very large number of interferometric modulators, and may have a different number of interferometric modulators in rows than in columns (e.g., 300 pixels per row by 190 pixels per column).

[0035] FIG. 3 is a diagram of movable mirror position versus applied voltage for one exemplary embodiment of an interferometric modulator of FIG. 1. For MEMS interferometric modulators, the row/column actuation protocol may take advantage of a hysteresis property of these devices as illustrated in Figure 3. An interferometric modulator

may require, for example, a 10 volt potential difference to cause a movable layer to deform from the relaxed state to the actuated state. However, when the voltage is reduced from that value, the movable layer maintains its state as the voltage drops back below 10 volts. In the exemplary embodiment of Figure 3, the movable layer does not relax completely until the voltage drops below 2 volts. There is thus a range of voltage, about 3 to 7 V in the example illustrated in Figure 3, where there exists a window of applied voltage within which the device is stable in either the relaxed or actuated state. This is referred to herein as the “hysteresis window” or “stability window.” For a display array having the hysteresis characteristics of Figure 3, the row/column actuation protocol can be designed such that during row strobing, pixels in the strobed row that are to be actuated are exposed to a voltage difference of about 10 volts, and pixels that are to be relaxed are exposed to a voltage difference of close to zero volts. After the strobe, the pixels are exposed to a steady state or bias voltage difference of about 5 volts such that they remain in whatever state the row strobe put them in. After being written, each pixel sees a potential difference within the “stability window” of 3-7 volts in this example. This feature makes the pixel design illustrated in Figure 1 stable under the same applied voltage conditions in either an actuated or relaxed pre-existing state. Since each pixel of the interferometric modulator, whether in the actuated or relaxed state, is essentially a capacitor formed by the fixed and moving reflective layers, this stable state can be held at a voltage within the hysteresis window with almost no power dissipation. Essentially no current flows into the pixel if the applied potential is fixed.

**[0036]** As described further below, in typical applications, a frame of an image may be created by sending a set of data signals (each having a certain voltage level) across the set of column electrodes in accordance with the desired set of actuated pixels in the first row. A row pulse is then applied to a first row electrode, actuating the pixels corresponding to the set of data signals. The set of data signals is then changed to correspond to the desired set of actuated pixels in a second row. A pulse is then applied to the second row electrode, actuating the appropriate pixels in the second row in accordance with the data signals. The first row of pixels are unaffected by the second row pulse, and remain in the state they were set to during the first row pulse. This may be repeated for the entire series of rows in a sequential fashion to produce the frame. Generally, the frames are refreshed and/or updated with new image data by continually repeating this process at some desired number of frames per second. A wide variety of protocols for driving row and column electrodes of pixel arrays to produce image frames may be used.

[0037] Figures 4 and 5 illustrate one possible actuation protocol for creating a display frame on the 3x3 array of Figure 2. Figure 4 illustrates a possible set of column and row voltage levels that may be used for pixels exhibiting the hysteresis curves of Figure 3. In the Figure 4 embodiment, actuating a pixel involves setting the appropriate column to  $-V_{\text{bias}}$ , and the appropriate row to  $+\Delta V$ , which may correspond to -5 volts and +5 volts respectively. Relaxing the pixel is accomplished by setting the appropriate column to  $+V_{\text{bias}}$ , and the appropriate row to the same  $+\Delta V$ , producing a zero volt potential difference across the pixel. In those rows where the row voltage is held at zero volts, the pixels are stable in whatever state they were originally in, regardless of whether the column is at  $+V_{\text{bias}}$ , or  $-V_{\text{bias}}$ . As is also illustrated in Figure 4, voltages of opposite polarity than those described above can be used, e.g., actuating a pixel can involve setting the appropriate column to  $+V_{\text{bias}}$ , and the appropriate row to  $-\Delta V$ . In this embodiment, releasing the pixel is accomplished by setting the appropriate column to  $-V_{\text{bias}}$ , and the appropriate row to the same  $-\Delta V$ , producing a zero volt potential difference across the pixel.

[0038] Figure 5B is a timing diagram showing a series of row and column signals applied to the 3x3 array of Figure 2 which will result in the display arrangement illustrated in Figure 5A, where actuated pixels are non-reflective. Prior to writing the frame illustrated in Figure 5A, the pixels can be in any state, and in this example, all the rows are initially at 0 volts, and all the columns are at +5 volts. With these applied voltages, all pixels are stable in their existing actuated or relaxed states.

[0039] In the Figure 5A frame, pixels (1,1), (1,2), (2,2), (3,2) and (3,3) are actuated. To accomplish this, during a "line time" for row 1, columns 1 and 2 are set to -5 volts, and column 3 is set to +5 volts. This does not change the state of any pixels, because all the pixels remain in the 3-7 volt stability window. Row 1 is then strobed with a pulse that goes from 0, up to 5 volts, and back to zero. This actuates the (1,1) and (1,2) pixels and relaxes the (1,3) pixel. No other pixels in the array are affected. To set row 2 as desired, column 2 is set to -5 volts, and columns 1 and 3 are set to +5 volts. The same strobe applied to row 2 will then actuate pixel (2,2) and relax pixels (2,1) and (2,3). Again, no other pixels of the array are affected. Row 3 is similarly set by setting columns 2 and 3 to -5 volts, and column 1 to +5 volts. The row 3 strobe sets the row 3 pixels as shown in Figure 5A. After writing the frame, the row potentials are zero, and the column potentials can remain at either +5 or -5 volts, and the display is then stable in the arrangement of Figure 5A. The same procedure

can be employed for arrays of dozens or hundreds of rows and columns. The timing, sequence, and levels of voltages used to perform row and column actuation can be varied widely within the general principles outlined above, and the above example is exemplary only, and any actuation voltage method can be used with the systems and methods described  
5 herein.

**[0040]** Figures 6A and 6B are system block diagrams illustrating an embodiment of a display device 40. The display device 40 can be, for example, a cellular or mobile telephone. However, the same components of display device 40 or slight variations thereof are also illustrative of various types of display devices such as televisions and portable media players.

10 **[0041]** The display device 40 includes a housing 41, a display 30, an antenna 43, a speaker 45, an input device 48, and a microphone 46. The housing 41 is generally formed from any of a variety of manufacturing processes, including injection molding, and vacuum forming. In addition, the housing 41 may be made from any of a variety of materials, including but not limited to plastic, metal, glass, rubber, and ceramic, or a combination thereof. In one  
15 embodiment the housing 41 includes removable portions (not shown) that may be interchanged with other removable portions of different color, or containing different logos, pictures, or symbols.

**[0042]** The display 30 of exemplary display device 40 may be any of a variety of displays, including a bi-stable display, as described herein. In other embodiments, the display 30  
20 includes a flat-panel display, such as plasma, EL, OLED, STN LCD, or TFT LCD as described above, or a non-flat-panel display, such as a CRT or other tube device,. However, for purposes of describing the present embodiment, the display 30 includes an interferometric modulator display, as described herein.

**[0043]** The components of one embodiment of exemplary display device 40 are  
25 schematically illustrated in Figure 6B. The illustrated exemplary display device 40 includes a housing 41 and can include additional components at least partially enclosed therein. For example, in one embodiment, the exemplary display device 40 includes a network interface 27 that includes an antenna 43 which is coupled to a transceiver 47. The transceiver 47 is connected to a processor 21, which is connected to conditioning hardware 52. The  
30 conditioning hardware 52 may be configured to condition a signal (e.g. filter a signal). The conditioning hardware 52 is connected to a speaker 45 and a microphone 46. The processor

21 is also connected to an input device 48 and a driver controller 29. The driver controller 29 is coupled to a frame buffer 28, and to an array driver 22, which in turn is coupled to a display array 30. A power supply 50 provides power to all components as required by the particular exemplary display device 40 design.

5 [0044] The network interface 27 includes the antenna 43 and the transceiver 47 so that the exemplary display device 40 can communicate with one ore more devices over a network. In one embodiment the network interface 27 may also have some processing capabilities to relieve requirements of the processor 21. The antenna 43 is any antenna for transmitting and receiving signals. In one embodiment, the antenna transmits and receives RF signals  
10 according to the IEEE 802.11 standard, including IEEE 802.11(a), (b), or (g). In another embodiment, the antenna transmits and receives RF signals according to the BLUETOOTH standard. In the case of a cellular telephone, the antenna is designed to receive CDMA, GSM, AMPS, W-CDMA, or other known signals that are used to communicate within a wireless cell phone network. The transceiver 47 pre-processes the signals received from the  
15 antenna 43 so that they may be received by and further manipulated by the processor 21. The transceiver 47 also processes signals received from the processor 21 so that they may be transmitted from the exemplary display device 40 via the antenna 43.

[0045] In an alternative embodiment, the transceiver 47 can be replaced by a receiver. In yet another alternative embodiment, network interface 27 can be replaced by an image source,  
20 which can store or generate image data to be sent to the processor 21. For example, the image source can be a digital video disc (DVD) or a hard-disc drive that contains image data, or a software module that generates image data.

[0046] Processor 21 generally controls the overall operation of the exemplary display device 40. The processor 21 receives data, such as compressed image data from the network  
25 interface 27 or an image source, and processes the data into raw image data or into a format that is readily processed into raw image data. The processor 21 then sends the processed data to the driver controller 29 or to frame buffer 28 for storage. Raw data typically refers to the information that identifies the image characteristics at each location within an image. For example, such image characteristics can include color, saturation, and gray-scale level.

30 [0047] In one embodiment, the processor 21 includes a microcontroller, CPU, or logic unit to control operation of the exemplary display device 40. Conditioning hardware 52 generally

includes amplifiers and filters for transmitting signals to the speaker 45, and for receiving signals from the microphone 46. Conditioning hardware 52 may be discrete components within the exemplary display device 40, or may be incorporated within the processor 21 or other components.

5 [0048] The driver controller 29 takes the raw image data generated by the processor 21 either directly from the processor 21 or from the frame buffer 28 and reformats the raw image data appropriately for high speed transmission to the array driver 22. Specifically, the driver controller 29 reformats the raw image data into a data flow having a raster-like format, such that it has a time order suitable for scanning across the display array 30. Then the driver controller 29 sends the formatted information to the array driver 22. Although a driver controller 29, such as a LCD controller, is often associated with the system processor 21 as a stand-alone Integrated Circuit (IC), such controllers may be implemented in many ways. They may be embedded in the processor 21 as hardware, embedded in the processor 21 as software, or fully integrated in hardware with the array driver 22.

10 [0049] Typically, the array driver 22 receives the formatted information from the driver controller 29 and reformats the video data into a parallel set of waveforms that are applied many times per second to the hundreds and sometimes thousands of leads coming from the display's x-y matrix of pixels.

[0050] In one embodiment, the driver controller 29, array driver 22, and display array 30 are appropriate for any of the types of displays described herein. For example, in one embodiment, driver controller 29 is a conventional display controller or a bi-stable display controller (e.g., an interferometric modulator controller). In another embodiment, array driver 22 is a conventional driver or a bi-stable display driver (e.g., an interferometric modulator display). In one embodiment, a driver controller 29 is integrated with the array driver 22. Such an embodiment is common in highly integrated systems such as cellular phones, watches, and other small area displays. In yet another embodiment, display array 30 is a typical display array or a bi-stable display array (e.g., a display including an array of interferometric modulators).

[0051] The input device 48 allows a user to control the operation of the exemplary display device 40. In one embodiment, input device 48 includes a keypad, such as a QWERTY keyboard or a telephone keypad, a button, a switch, a touch-sensitive screen, a pressure- or

heat-sensitive membrane. In one embodiment, the microphone 46 is an input device for the exemplary display device 40. When the microphone 46 is used to input data to the device, voice commands may be provided by a user for controlling operations of the exemplary display device 40.

5 [0052] Power supply 50 can include a variety of energy storage devices as are well known in the art. For example, in one embodiment, power supply 50 is a rechargeable battery, such as a nickel-cadmium battery or a lithium ion battery. In another embodiment, power supply 50 is a renewable energy source, a capacitor, or a solar cell, including a plastic solar cell, and solar-cell paint. In another embodiment, power supply 50 is configured to receive power  
10 from a wall outlet.

[0053] In some implementations control programmability resides, as described above, in a driver controller which can be located in several places in the electronic display system. In some cases control programmability resides in the array driver 22. The above-described optimization may be implemented in any number of hardware and/or software components  
15 and in various configurations.

[0054] The details of the structure of interferometric modulators that operate in accordance with the principles set forth above may vary widely. For example, Figures 7A-7E illustrate five different embodiments of the movable reflective layer 14 and its supporting structures. Figure 7A is a cross section of the embodiment of Figure 1, where a strip of metal material 14  
20 is deposited on orthogonally extending supports 18. In Figure 7B, the moveable reflective layer 14 of each interferometric modulator is square or rectangular in shape and attached to supports at the corners only, on tethers 32. In Figure 7C, the moveable reflective layer 14 is square or rectangular in shape and suspended from a deformable layer 34, which may comprise a flexible metal. The deformable layer 34 connects, directly or indirectly, to the  
25 substrate 20 around the perimeter of the deformable layer 34. These connections are herein referred to as support posts. The embodiment illustrated in Figure 7D has support post plugs 42 upon which the deformable layer 34 rests. The movable reflective layer 14 remains suspended over the gap, as in Figures 7A-7C, but the deformable layer 34 does not form the support posts by filling holes between the deformable layer 34 and the optical stack 16.  
30 Rather, the support posts are formed of a planarization material, which is used to form support post plugs 42. The embodiment illustrated in Figure 7E is based on the embodiment shown in Figure 7D, but may also be adapted to work with any of the embodiments

illustrated in Figures 7A-7C as well as additional embodiments not shown. In the embodiment shown in Figure 7E, an extra layer of metal or other conductive material has been used to form a bus structure 44. This allows signal routing along the back of the interferometric modulators, eliminating a number of electrodes that may otherwise have had to be formed on the substrate 20.

[0055] In embodiments such as those shown in Figure 7, the interferometric modulators function as direct-view devices, in which images are viewed from the front side of the transparent substrate 20, the side opposite to that upon which the modulator is arranged. In these embodiments, the reflective layer 14 optically shields the portions of the interferometric modulator on the side of the reflective layer opposite the substrate 20, including the deformable layer 34. This allows the shielded areas to be configured and operated upon without negatively affecting the image quality. For example, such shielding allows the bus structure 44 in Figure 7E, which provides the ability to separate the optical properties of the modulator from the electromechanical properties of the modulator, such as addressing and the movements that result from that addressing. This separable modulator architecture allows the structural design and materials used for the electromechanical aspects and the optical aspects of the modulator to be selected and to function independently of each other. Moreover, the embodiments shown in Figures 7C-7E have additional benefits deriving from the decoupling of the optical properties of the reflective layer 14 from its mechanical properties, which are carried out by the deformable layer 34. This allows the structural design and materials used for the reflective layer 14 to be optimized with respect to the optical properties, and the structural design and materials used for the deformable layer 34 to be optimized with respect to desired mechanical properties.

#### Integrated Touch

[0056] Figure 8A illustrates components of an IMOD display 100 in an undeflected (equilibrium) position prior to a touch. Figure 8B illustrates display 100 in a deflected state when touched by an object such as a finger.

[0057] An advantage of such an IMOD display is that it is easily read in a variety of lighting situations. For example, while some displays may be washed out and difficult or impossible to read in bright sunlight, the IMOD display is reflective and easily read in bright sunlight. Typically, IMOD display 100 relies on ambient light, although a light source may be



integrated at the side of the display. As the display typically relies on ambient light, placing a touch sensitive screen element at the front side (that nearest the user and possible to touch) of the display will lessen the amount of light arriving at the pixels of the display and reflected to the user. Additionally, such a touch screen element may introduce an amount of optical distortion as light rays pass through the element to and from the reflective pixels. Embodiments of the display 100 avoid these drawbacks by integrating an electrode and using that electrode with other elements of the IMOD display to determine the position of a touch.

[0058] Referring to FIGS. 8A and 8B, the display 100 comprises a rear substrate 102, also referred to as back glass 102, an electrode 104 in contact with the surface of the back glass 102, and an electrode 108 of the mechanical layer. Electrode 108 may be any of the patterned electrode layers of the display, as described above in the previous section entitled Interferometric Modulator. Electrode 108 and other associated layers may hereafter be described as the “mechanical layer.” The electrode 104 is patterned in such a way that it is substantially orthogonal to the pattern of an electrode 108 of the mechanical layer of the display. For example, electrode 104 on the back glass may be patterned in rows, while the electrode of the mechanical layer is patterned in columns, as seen in Figure 8C. Of course, electrodes 104 and 108 need not be in a vertical or horizontal direction, but may be in at any angle from vertical and may deviate in path from a straight line, so long as the intersection of the electrodes occurs within a sufficiently finite area for acceptable touch recognition and resolution. Although for descriptive purposes the electrodes used to sense a touch are described in the context of a display, touch sensing can be achieved in any MEMS device by adding electrodes (104) at the back plate of the MEMS device. It should be understood that the present invention is not limited to display devices.

[0059] Display 100 may also comprise an insulator 106 between the mechanical layer and its electrode 108 and electrode 104 in embodiments where the deflection from a touch may result in contact of the mechanical layer and the electrode 104. Display 100 further comprises front (transparent) substrate 112 referred to hereafter as the IMOD substrate, seal 110, and absorber/ oxide layer 114 which may, for example, be patterned in rows or columns or in other orientation. Substrate 112 may or may not be transparent, depending on the apparatus and the application. For example, in a MEMS device other than a display, substrate 112 may not be transparent.

[0060] As seen in Figure 8B when an object such as a finger touches the IMOD substrate

112, it will deflect together with the absorber oxide 114 and the mechanical layer/electrode 108. This deflection, and the associated change in the gap between the mechanical layer electrode 108 or absorber/oxide layer 114 and electrode layer 104 results in a change in an electrical parameter that can be sensed in order to determine the location of the touch. Note also that deflection generated at the back glass may also be sensed, as such deflection also results in a change of capacitance or other parameter. Note that a touch may also be made and sensed through the back substrate 102 in Figures 8 and that mechanical layer 108 may not contact layer 106. A touch made by finger, stylus or even localized pressure may be sensed.

10 **[0061]** Figure 8D is a cross section of a two state embodiment of an interferometric modulator. This embodiment is referred to as “two state” because the mirrors of the mechanical layer 108 may be driven (e.g. pulled) towards either back glass 102 or IMOD substrate 112. In such an embodiment, the mirrors are driven towards the back glass 102 by top electrode/plate 116. The top electrode 116 is patterned in rows or columns or at another angle substantially orthogonal to the pattern of electrode 104 and thus may also be used to determine the location of a touch.

**[0062]** In one embodiment, the system senses the location of the touch by determining a change in capacitance at the intersection of the columns and rows or otherwise orthogonally oriented electrodes. Utilizing a processor of the system, embodiments compute the profile or shape of the deflected substrate by measuring capacitance at various locations and then comparing that shape with a model to compute the location of a touch. Such a display may be of a projected capacitive or surface capacitive nature. The embodiments shown in FIGS. 9A-D may be used to sense the touch area of interest, which may vary from the sub-pixel modulator scale to an entire screen or portion thereof. In one projected capacitive embodiment, because spatial resolution requirements for resolving a touch are much lower than the resolution of the display (and hence the electrodes of the mechanical or other layer) multiple adjacent mechanical lines may be connected together and sensed simultaneously, as seen in Figure 9A. In another embodiment, a matrix of touch sensors on the back glass are used while the mechanical layer electrodes are used only to supply a common reference voltage, as seen in Figure 9B. In surface capacitive embodiments the back glass layer may be a single conductor (electrode), rather than being patterned, as seen in Figure 9C, and an n-probe measure may be used. For example, n may be four and thus a four probe measurement

method is employed. In such an embodiment, patterned line electrodes of the mechanical layer are used to supply a reference voltage. Additionally, in embodiments where the IMOD display is a tri-state or a three dimensional analog IMOD device (with multiple sets of drive electrodes, as for example in FIG. 8D), a top plate of the device may be used to supply a  
5 reference voltage, as seen in Figure 9D.

[0063] The centroid of the capacitance change may also be computed from measured capacitance data to improve touch sensing resolution and also to allow for multi touch (e.g. two or more fingers or other objects simultaneously) sensing. The centroid of capacitance change need not coincide with the location of the touch. For multi touch, superposition of the  
10 shape is a linear combination of the shapes resulting from the individual touches. A mapping between the centroid and touch location may be stored in memory, and referenced as needed. The mapping data can be based on mathematical (i.e. theoretical) calculations or on actual calibration values for a particular product line or individual display.

[0064] As an example, for a 3.5 inch panel and a six micron gap between the mechanical  
15 layer electrode and the back glass electrode, capacitance from the whole panel is approximately six nano farads. Assuming a two micron deflection occurs as the result of a touch, greater than one nanofarad total capacitance change may result, which is sufficiently detected by the described embodiments.

[0065] Other electrical parameters may also be used such as the resistance across the back  
20 glass electrode and/or electrode of the mechanical layer or absorber/oxide layer or an electrical circuit connected thereto. In such embodiments, the insulated layer between the electrodes is preferably not present.

[0066] Referring to FIGS. 10A and 10B a group of posts 130 may be formed within back  
25 glass 102. Recesses 120 between the posts are filled with desiccant. A number of different geometric shapes and patterns may be used for the posts and resultant recesses. For example, an array of hexagons may be patterned such as that shown in Figure 10B. Other geometric shapes may include circular, triangular, rectangular, pentagonal, octagonal columns etc. The back glass electrode 104 would be patterned to fit atop the posts and be interconnected in rows or columns or other orientations. Density may also be varied from center to edge to aid  
30 in detection and the panel edges, which are often more difficult to resolve than in the central portion of the display.

[0067] In certain embodiments, an appropriate insulator may be placed on top of the back glass electrode 104 to aid in capacitance detection as well as prevent wear of the mechanical layer. Examples of insulating layers would include silicon dioxide, liquid crystal polymer and Teflon etc.

5 [0068] FIG. 11 is a flow chart depicting an overview of device fabrication. The following steps are not necessarily in the order described. In step 204, the array of interferometric modulators is formed. Then in step 208, the absorber layer is formed, and in step 21 the top electrode/plate is formed in embodiments where present. In step 216 the posts in the back glass are formed and in step 220 the desiccant between the posts or present in other areas is  
10 provided. In step 224, the back glass electrode is formed, and in step 228, the seals are formed and the array substrate is attached to the back glass (opposing substrate).

[0069] While the invention has been particularly shown and described with reference to specific embodiments thereof, it will be understood by those skilled in the art that changes in the form and details of the disclosed embodiments may be made without departing from the  
15 spirit or scope of the invention.

[0070] In addition, although various advantages, aspects, and objects of the present invention have been discussed herein with reference to various embodiments, it will be understood that the scope of the invention should not be limited by reference to such advantages, aspects, and objects. Rather, the scope of the invention should be determined with reference to the  
20 appended claims.

**THE CLAIMS**

What is claimed is:

5

1. An apparatus, comprising:

a first substrate;

an array of microelectromechanical elements disposed on the first substrate;

a first plurality of electrodes configured for conducting electrical signals to the array

10 of microelectromechanical elements;

first control circuitry configured to apply electrical signals for controlling the array of microelectromechanical elements via the first plurality of electrodes;

a second substrate;

a second plurality of electrodes disposed on the second substrate; and

15

second control circuitry configured to detect capacitance changes between the first plurality of electrodes and the second plurality of electrodes and to determine a deflected area of the first substrate based, at least in part, on the capacitance changes.

2. The apparatus of claim 1, wherein the array of microelectromechanical elements

20

comprises interferometric modulation elements, the interferometric modulation elements comprising two walls that define a cavity, one of the walls being movable relative to the other through a range of positions, the walls causing the cavity to operate interferometrically in at least one of the positions, producing a predetermined optical response to visible light.

25

3. The apparatus of claim 1 or claim 2, wherein the first substrate is substantially transparent.

4. The apparatus of any of claims 1 through 3, wherein the second control circuitry is further configured to compute a centroid of the capacitance change.

30

5. The apparatus of claim 4, wherein the second control circuitry is further configured to reference a stored map of centroid capacitance change versus intersection data and determine the location of the touch.

6. The apparatus of claim 5, wherein the second control circuitry is further configured to compute the centroid of a multi point touch.
7. The apparatus of any of claims 1 through 6, wherein the first plurality of electrodes is  
5 part of an optical stack disposed on the first substrate.
8. The apparatus of any of claims 1 through 7, wherein the first plurality of electrodes is adjacent the first substrate.
- 10 9. The apparatus of claim 8, wherein the first plurality of electrodes is located between the array of microelectromechanical elements and the first substrate.
10. The apparatus of any of claims 1 through 9, wherein multiple adjacent of the first plurality of electrodes are connected together and sensed simultaneously.
- 15 11. The apparatus of any of claims 1 through 10, wherein the apparatus comprises:  
a display;  
a processor that is configured to communicate with said display, said processor being configured to process image data; and  
20 a memory device that is configured to communicate with said processor.
12. The apparatus as recited in claim 11, further comprising:  
a driver circuit configured to send at least one signal to said display.
- 25 13. The apparatus as recited in claim 12, further comprising:  
a controller configured to send at least a portion of said image data to said driver circuit.
14. The apparatus as recited in claim 11, further comprising:  
an image source module configured to send said image data to said processor.
- 30 15. The apparatus as recited in claim 14, wherein said image source module comprises at least one of a receiver, transceiver, and transmitter.
16. The apparatus as recited in claim 11, further comprising:

an input device configured to receive input data and to communicate said input data to said processor.

17. An apparatus having a display with a front display side and a rear display side, the apparatus comprising:
- a first substantially transparent substrate;
  - an array of interferometric modulation elements disposed on the first substantially transparent substrate, the interferometric modulation elements comprising two walls that define a cavity, one of the walls being movable relative to the other through a range of positions, the walls causing the cavity to operate interferometrically in at least one of the positions, producing a predetermined optical response to visible light;
  - a first plurality of electrodes configured for conducting electrical signals to the array of interferometric modulation elements;
  - first control circuitry configured to apply electrical signals for controlling the array of interferometric modulation elements via the first plurality of electrodes;
  - a second substrate at the rear display side; and
  - planar sensing means located at the rear display side for sensing a touch and an associated change in an electrical parameter between a portion of the planar sensing means and the first plurality of electrodes.
18. The apparatus of claim 17, further comprising a second plurality of electrodes configured for conducting electrical signals to the array of interferometric modulation elements.
19. The apparatus of claim 18, wherein the planar sensing means located at the rear display side is further configured to sense an associated change in the electrical parameter between a portion of the planar sensing means and the second plurality of electrodes.
20. A method of making and operating an interferometric display apparatus, comprising:
- providing a front substrate at a front of the display, the front substrate being substantially transparent;
  - providing a rear substrate at a rear of the display, the rear substrate being substantially transparent;

providing an array of interferometric modulation elements disposed between the front and rear substrates,

the array disposed on the front substrate at the front of the display, the interferometric modulation elements comprising two walls that define a cavity, one of the walls being  
5 movable relative to the other through a range of positions, the walls causing the cavity to operate interferometrically in at least one of the positions, producing a predetermined optical response to visible light;

providing a first plurality of electrodes oriented along a first axis and configured for conducting electrical signals to the array of interferometric modulation elements, the first  
10 plurality of electrodes in contact with the rear substrate;

providing a second plurality of electrodes oriented along a second axis substantially orthogonal to the first axis;

utilizing one or both of the first or second plurality of electrodes as plates of a touch screen, and sensing a change in a parameter generated by a touch at the intersection between  
15 the electrodes of the first and second plurality.

21. The method of claim 20, wherein sensing a change in a parameter generated by a touch comprises sensing a change in capacitance at the intersection between the electrodes of the first and second plurality.

20

22. The method of claim 20 or claim 21, wherein sensing a change in a parameter generated by a touch comprises sensing a change in resistance at the intersection between the electrodes of the first and second plurality.

25

23. The method of claim 21, further comprising computing a centroid of the capacitance change.

24. The method of claim 23, further comprising referencing a stored map of centroid capacitance change vs. intersection data and determining the location of the touch.

30

25. The method of claim 24, further comprising computing the centroid of a multi point touch.



26. The method of claim 20, further comprising providing a plurality of posts within the rear substrate.
27. The method of any of claims 20 through 26, wherein the first plurality of electrodes  
5 are disposed atop the posts.
28. The method of claim 26, further comprising providing desiccant between the plurality of posts within the substrate.
- 10 29. A method of making and operating an interferometric display apparatus, comprising:  
forming an array of interferometric modulators on an array substrate;  
forming an absorber layer;  
providing a second substrate opposing the array substrate;  
forming an electrode at the second substrate; and  
15 forming a seal and attaching the array substrate and opposing second substrate.
30. The method of claim 29, further comprising forming a top plate electrode.
31. The method of claim 29 or claim 30, further comprising forming posts within the  
20 second substrate and providing desiccant between the posts.
32. The method of claim 31, wherein forming the electrode at the second substrate comprises patterning the electrode atop the posts.
- 25 33. The method of claim 30, wherein the further comprising supplying a reference voltage to the top plate electrode and determining the location of a touch by detecting a capacitance change between the top plate and a conductor of the interferometric display.
34. The method of claim 30, wherein the electrode at the second substrate comprises  
30 [further comprising] providing a matrix of touch sensors [on the second substrate] and the method further comprises supplying a reference voltage to an electrode of the array of interferometric modulators and detecting a change in capacitance between one of the matrix of touch sensors and the electrode of the array.

35. The method of claim 30, wherein forming the electrode at the second substrate comprises forming a single unpatterned conductive plate, and wherein the method further comprises determining the position of a touch by providing a reference voltage to patterned line electrodes of the array of interferometric modulators and determining a change in
- 5 capacitance between the patterned line electrodes and the unpatterned conductive plate.

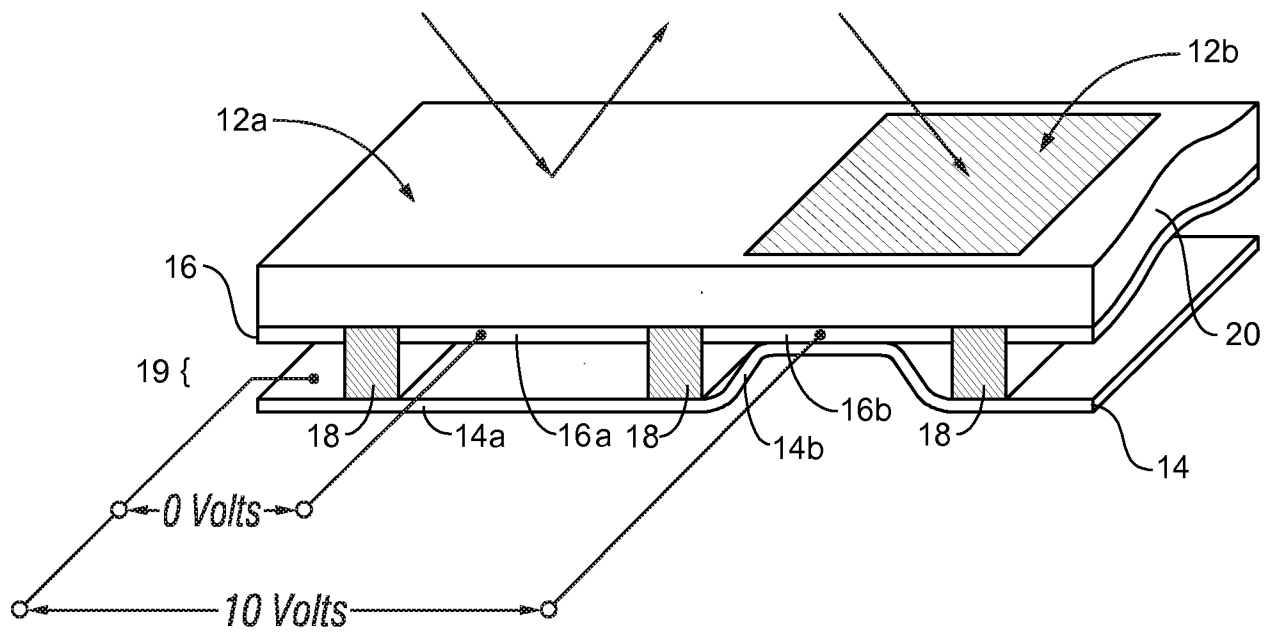


FIG. 1

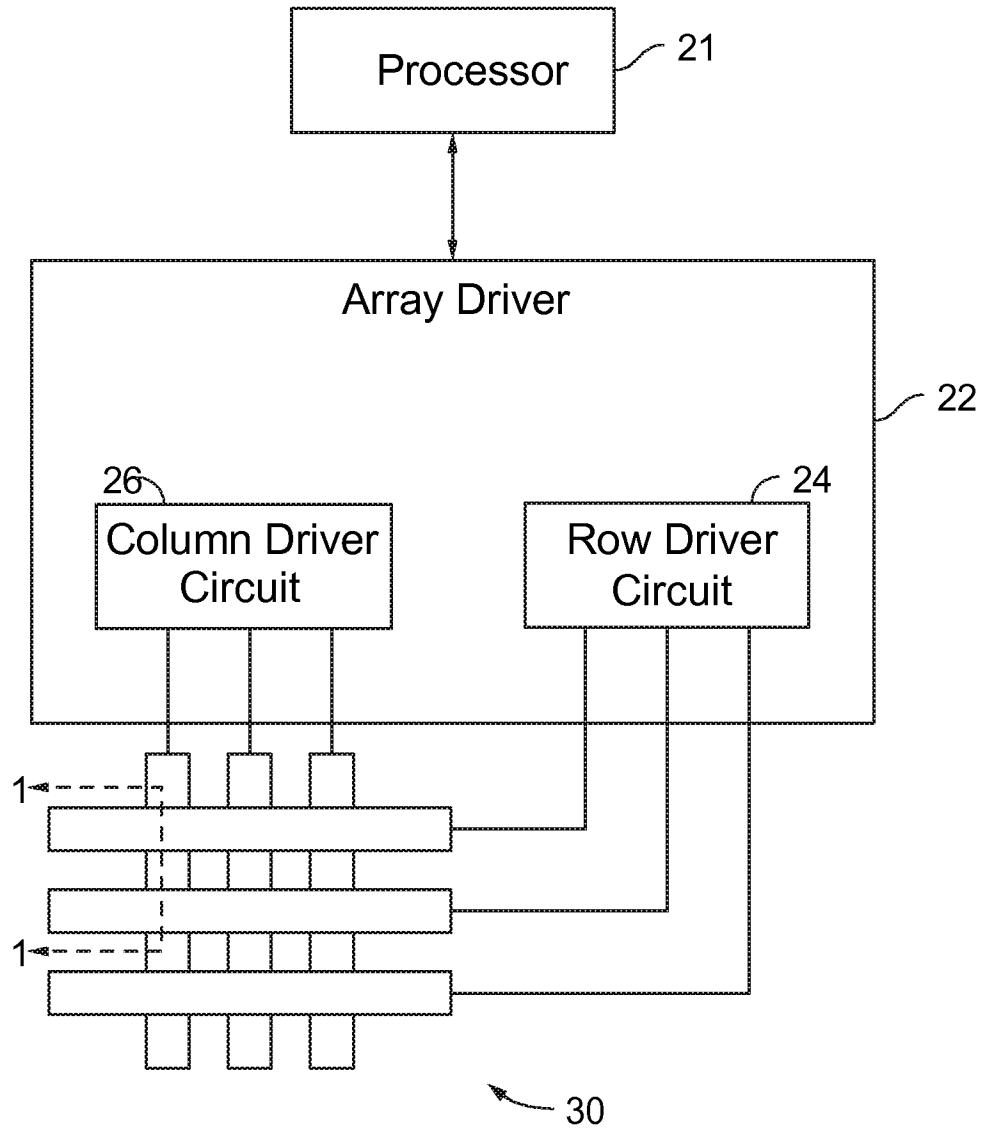


FIG. 2

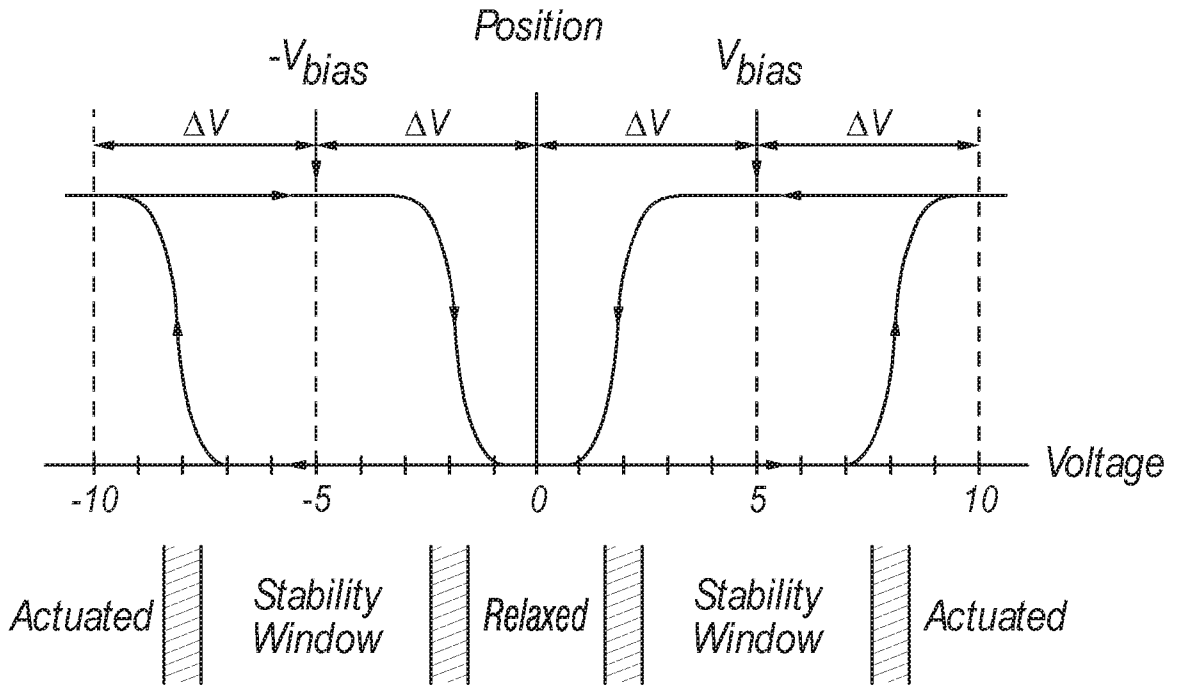


FIG. 3

		Column Output Signals	
		$+ V_{bias}$	$-V_{bias}$
Row Output Signals	0	Stable	Stable
	$+ \Delta V$	Relax	Actuate
	$-\Delta V$	Actuate	Relax

FIG. 4

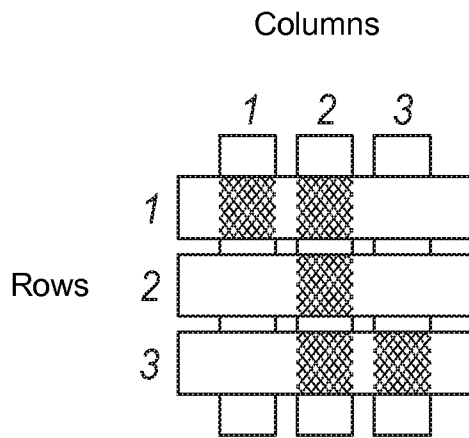


FIG. 5A

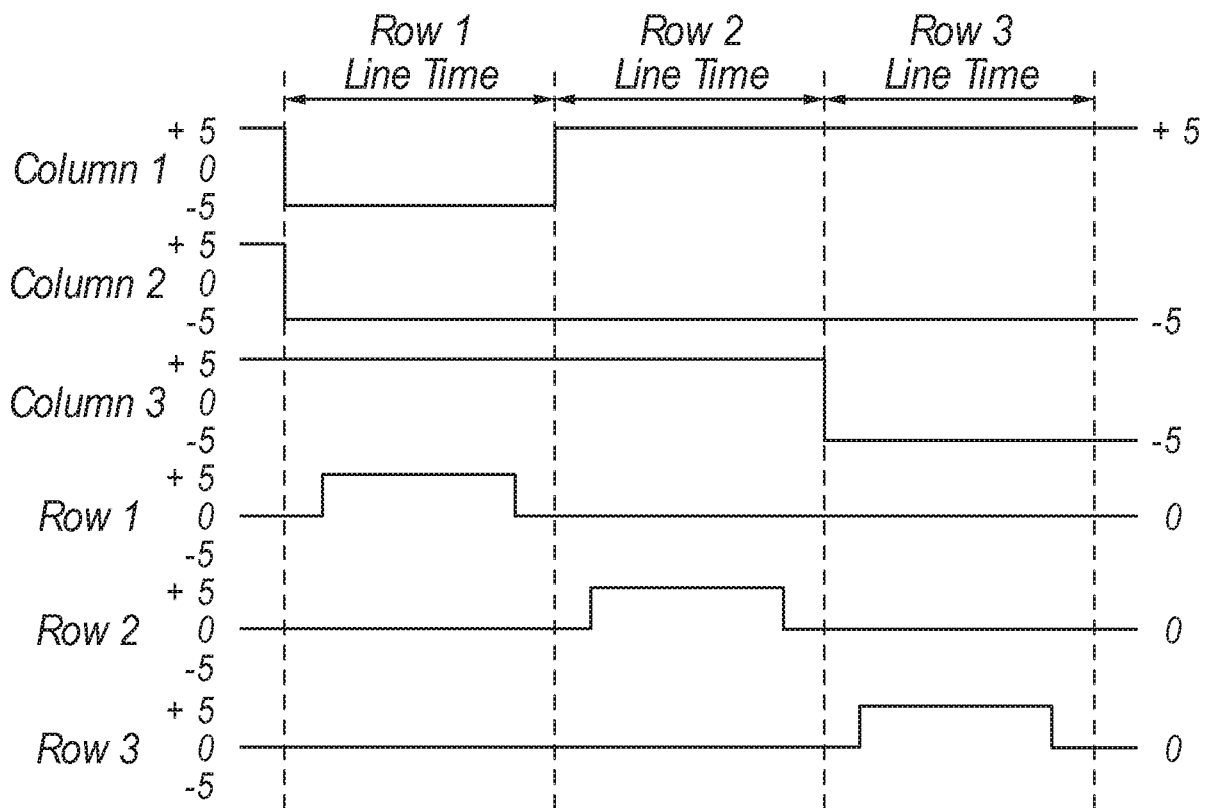


FIG. 5B

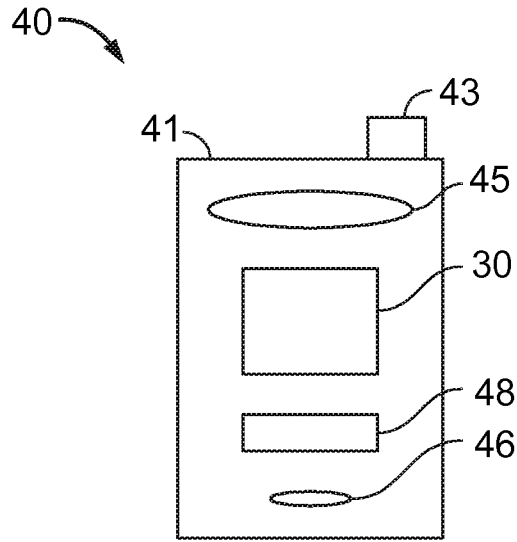


FIG. 6A

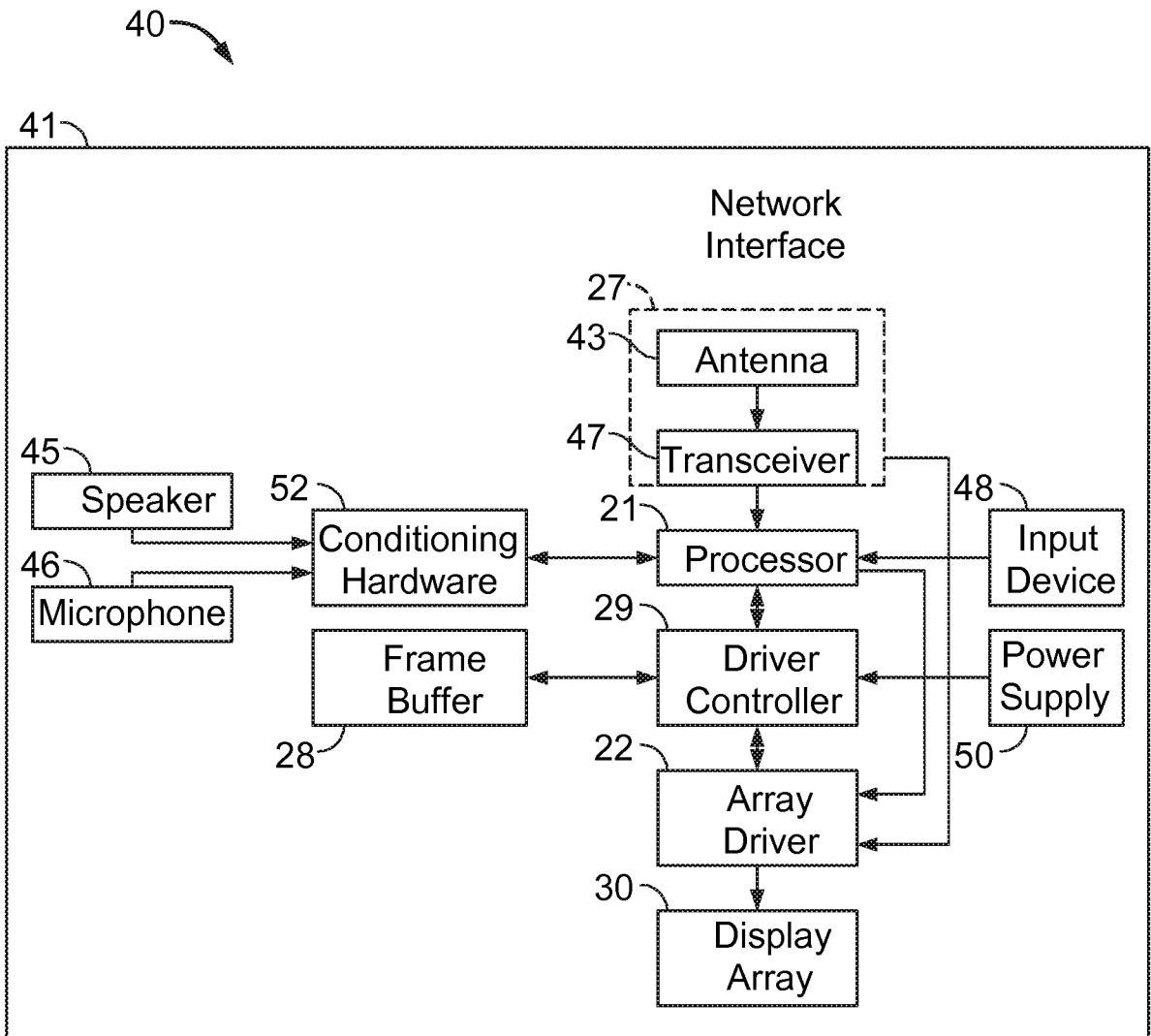


FIG. 6B

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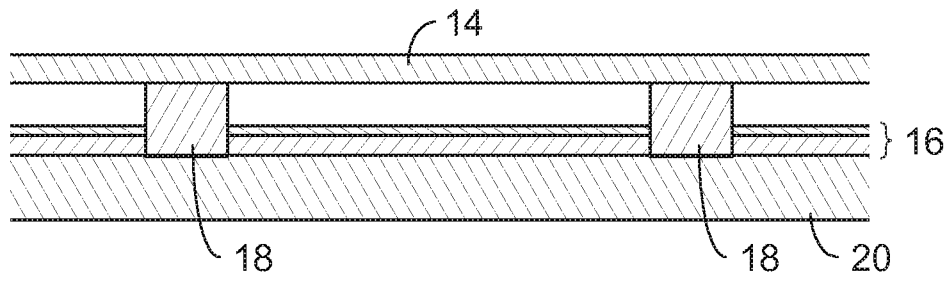


FIG. 7A

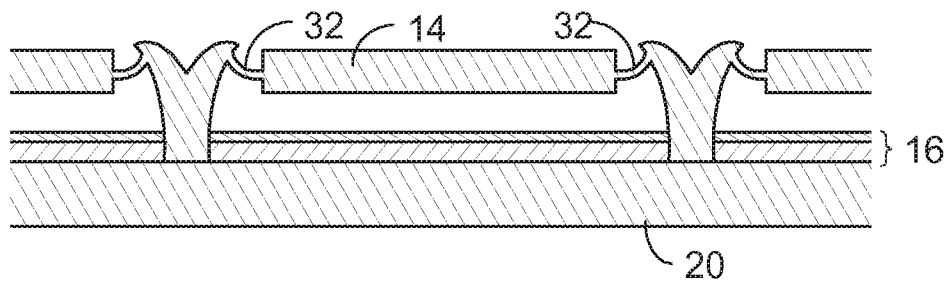


FIG. 7B

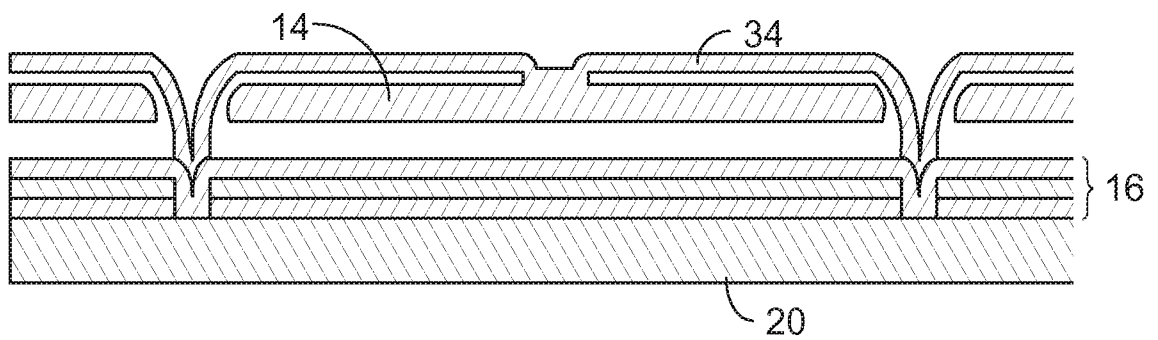


FIG. 7C



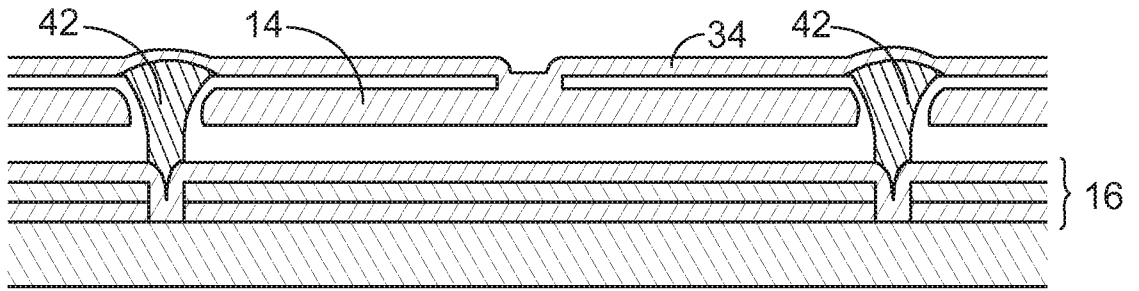


FIG. 7D

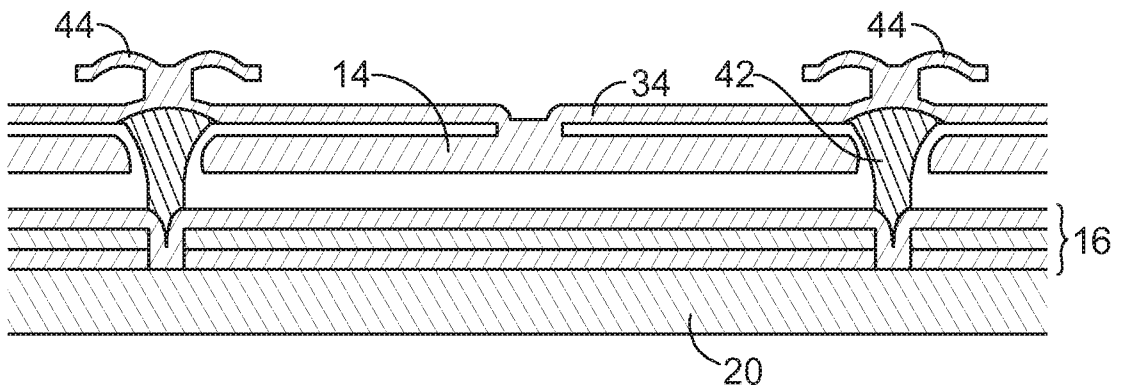


FIG. 7E

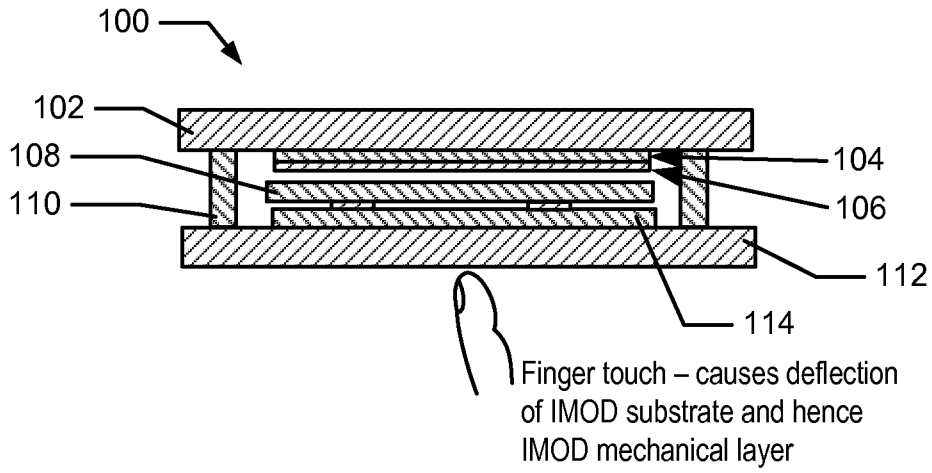


FIG. 8A

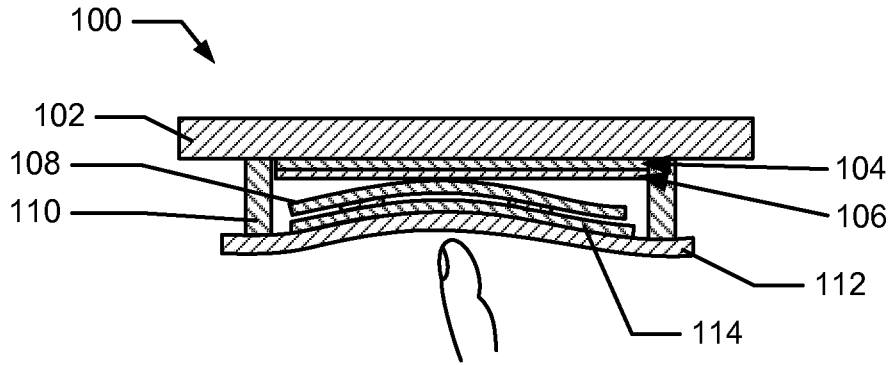


FIG. 8B

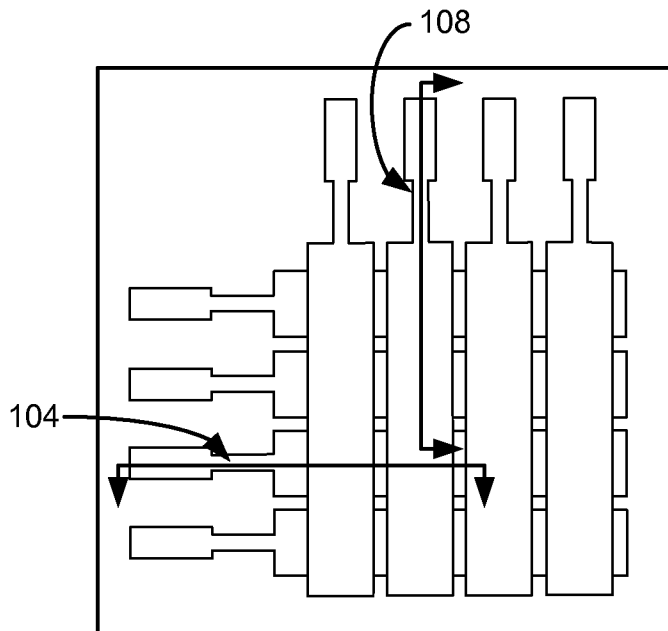


FIG. 8C

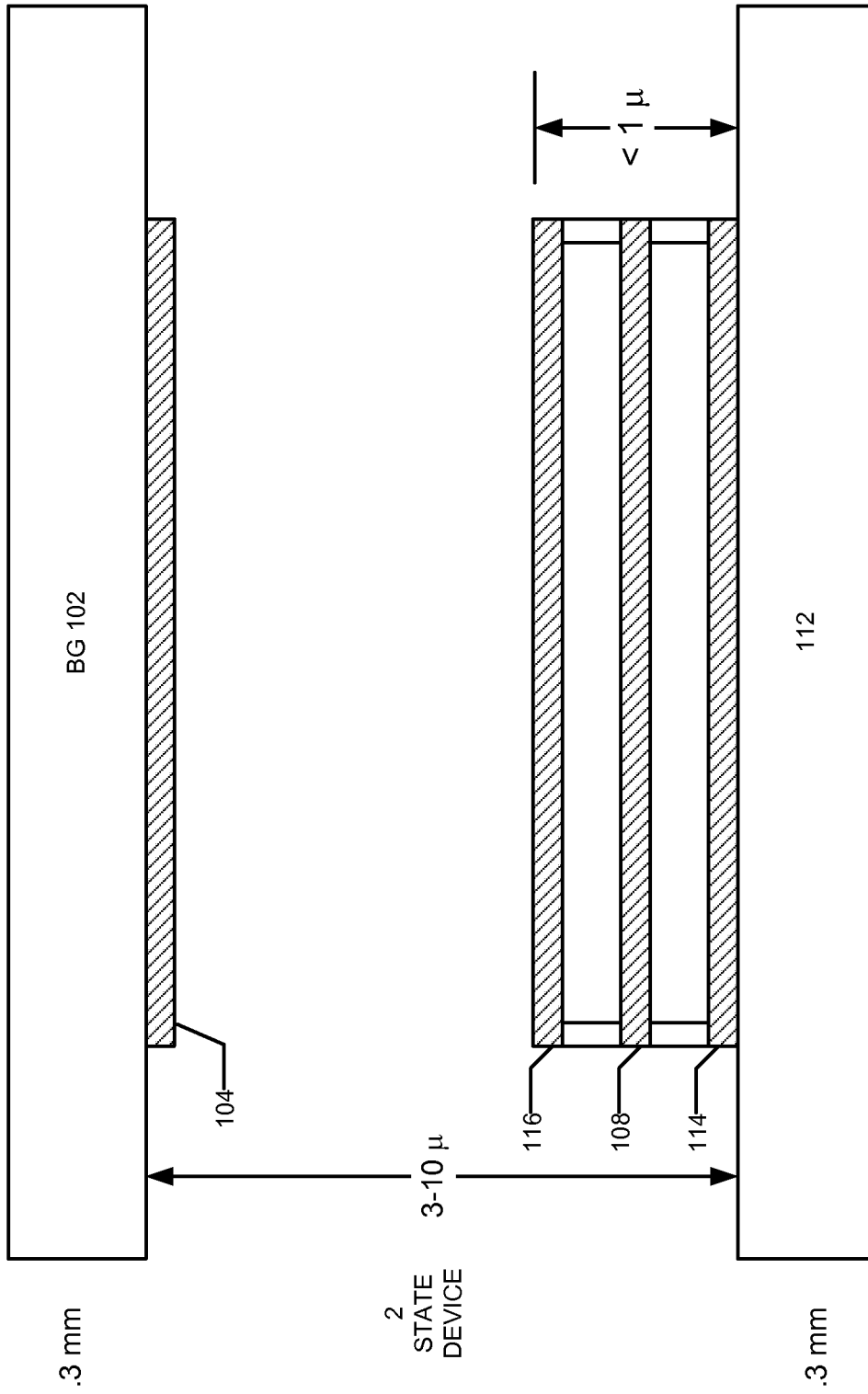


FIG. 8D

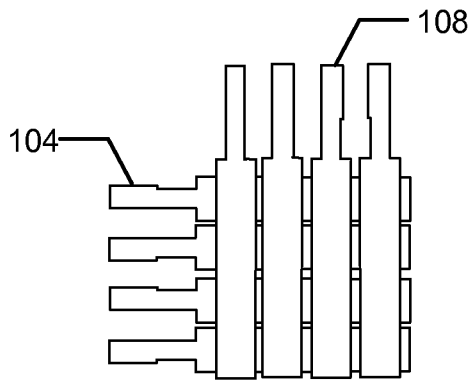


FIG. 9A

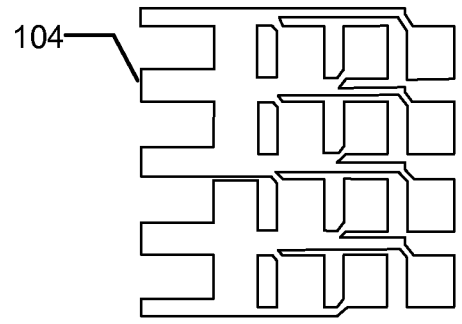


FIG. 9B

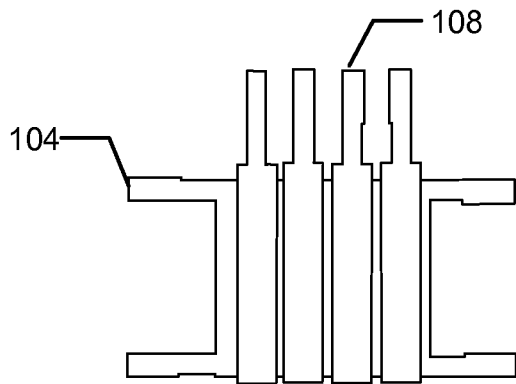


FIG. 9C

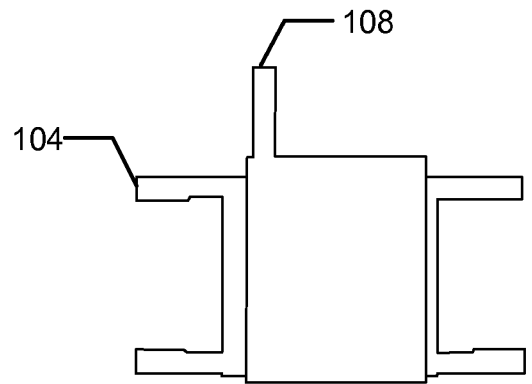


FIG. 9D

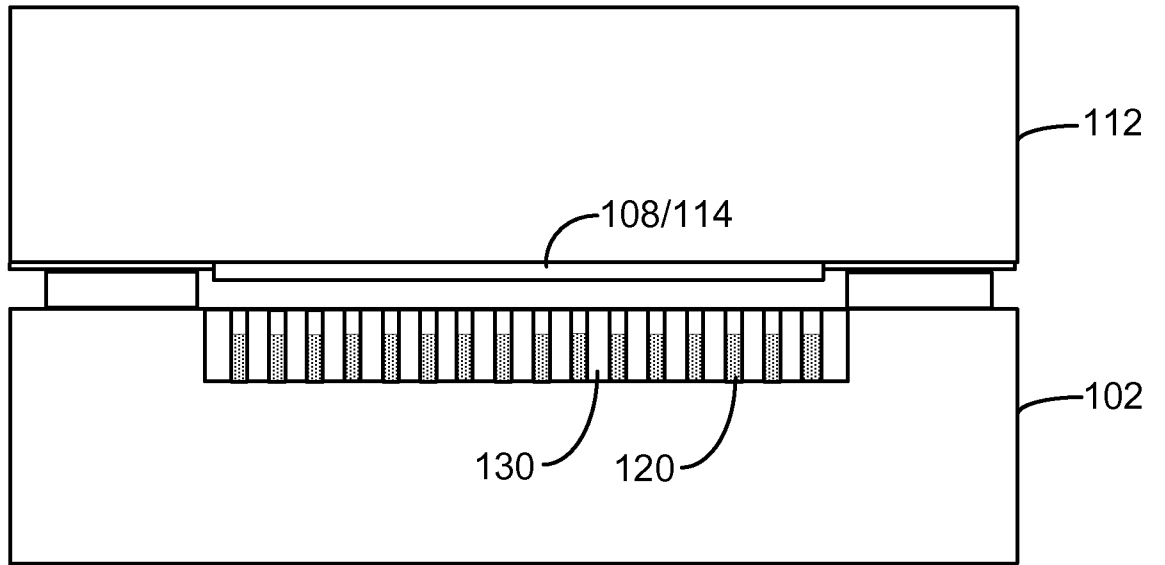


FIG. 10A

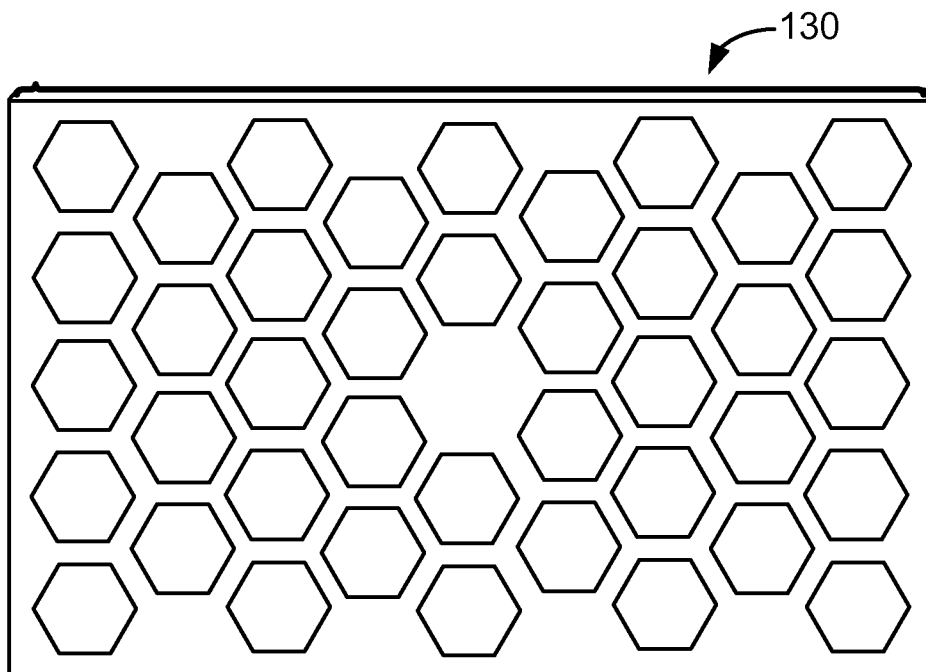


FIG. 10B

12/12

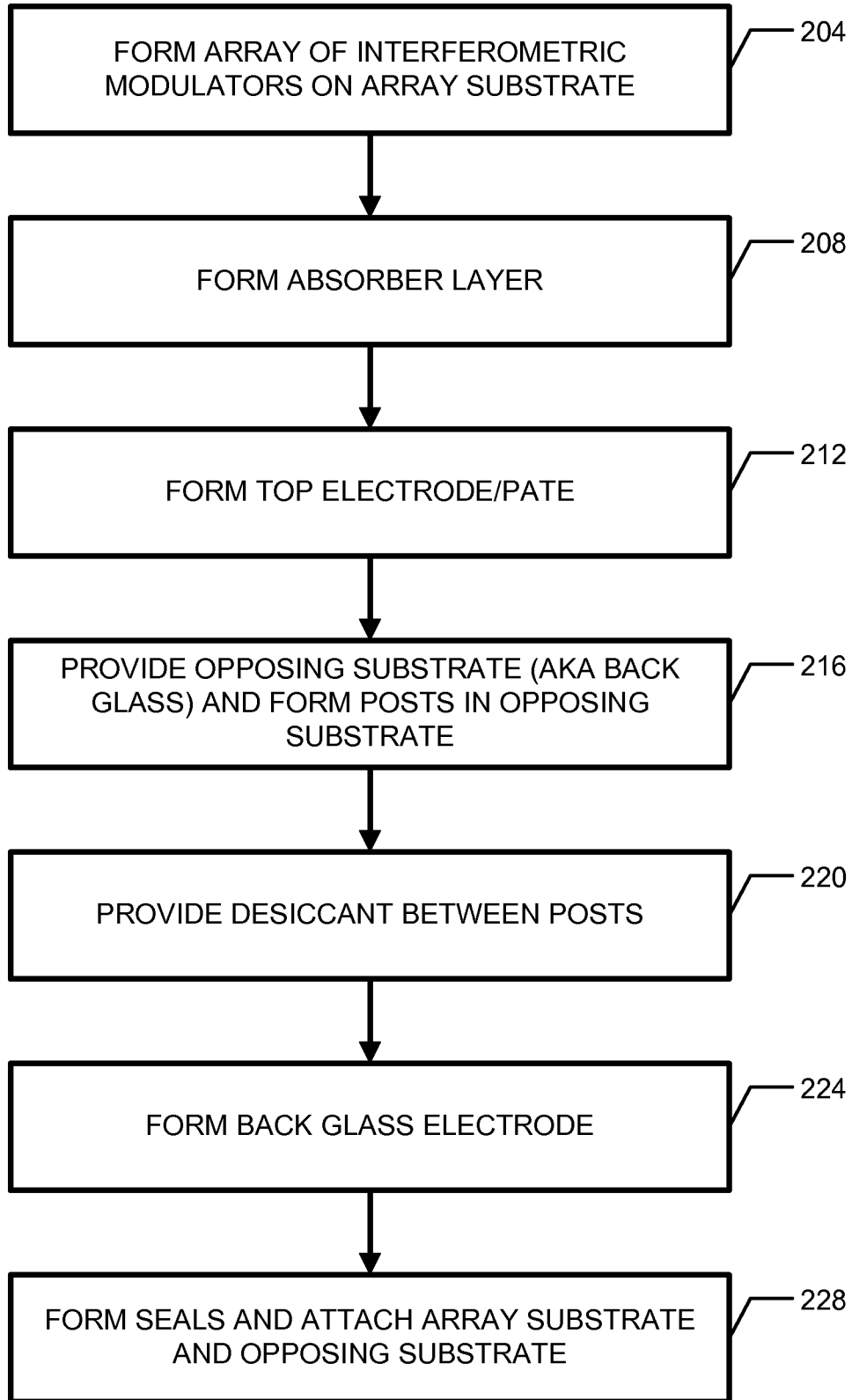


FIG. 11

INTERNATIONAL SEARCH REPORT

International application No  
PCT/US2010/060584

A. CLASSIFICATION OF SUBJECT MATTER  
INV. G02B26/00 G06F3/044  
ADD.  
According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED  
Minimum documentation searched (classification system followed by classification symbols)  
G02B G06F  
Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)  
EPO-Internal

C. DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 2006/044928 A1 (CHUI CLARENCE [US] ET AL) 2 March 2006 (2006-03-02)	1-4, 7-21, 23, 26-35
A	paragraphs [0042] - [0076]	5, 6, 24, 25
X	EP 1 630 781 A2 (IDC LLC [US]) 1 March 2006 (2006-03-01)	1
A	paragraphs [0012] - [0041]	
A	US 2007/075942 A1 (MARTIN ERIC [US] ET AL) 5 April 2007 (2007-04-05)	1-35
A	paragraphs [0012] - [0028]	
A	US 2009/195518 A1 (MATTICE HAROLD E [US] ET AL) 6 August 2009 (2009-08-06)	1-35
	paragraphs [0017] - [0120]	
	-/--	

Further documents are listed in the continuation of Box C.

See patent family annex.

\* Special categories of cited documents :

- "A" document defining the general state of the art which is not considered to be of particular relevance
- "E" earlier document but published on or after the international filing date
- "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)
- "O" document referring to an oral disclosure, use, exhibition or other means
- "P" document published prior to the international filing date but later than the priority date claimed

- "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
- "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
- "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art.
- "&" document member of the same patent family

Date of the actual completion of the international search 14 February 2011	Date of mailing of the international search report 13/05/2011
Name and mailing address of the ISA/ European Patent Office, P.B. 5818 Patentlaan 2 NL - 2280 HV Rijswijk Tel. (+31-70) 340-2040, Fax: (+31-70) 340-3016	Authorized officer Stemmer, Michael

# INTERNATIONAL SEARCH REPORT

International application No.  
PCT/US2010/060584

## Box No. II Observations where certain claims were found unsearchable (Continuation of item 2 of first sheet)

This international search report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:

1.  Claims Nos.:  
because they relate to subject matter not required to be searched by this Authority, namely:
  
2.  Claims Nos.:  
because they relate to parts of the international application that do not comply with the prescribed requirements to such an extent that no meaningful international search can be carried out, specifically:
  
3.  Claims Nos.:  
because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).

## Box No. III Observations where unity of invention is lacking (Continuation of item 3 of first sheet)

This International Searching Authority found multiple inventions in this international application, as follows:

see additional sheet

1.  As all required additional search fees were timely paid by the applicant, this international search report covers all searchable claims.
  
2.  As all searchable claims could be searched without effort justifying an additional fees, this Authority did not invite payment of additional fees.
  
3.  As only some of the required additional search fees were timely paid by the applicant, this international search report covers only those claims for which fees were paid, specifically claims Nos.:
  
4.  No required additional search fees were timely paid by the applicant. Consequently, this international search report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:  
  
1-21, 23-35

### Remark on Protest

- The additional search fees were accompanied by the applicant's protest and, where applicable, the payment of a protest fee.
- The additional search fees were accompanied by the applicant's protest but the applicable protest fee was not paid within the time limit specified in the invitation.
- No protest accompanied the payment of additional search fees.



# INTERNATIONAL SEARCH REPORT

International application No  
PCT/US2010/060584

C(Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	US 3 593 115 A (DYM HERBERT ET AL) 13 July 1971 (1971-07-13) column 2, line 27 - column 6, line 18 -----	1-35

# INTERNATIONAL SEARCH REPORT

Information on patent family members

International application No

PCT/US2010/060584

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**FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 210**

This International Searching Authority found multiple (groups of) inventions in this international application, as follows:

1. claims: 1-21, 23-35

an apparatus and a method for sensing the change in capacitance for elements of an array;

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2. claim: 22

an apparatus and a method for sensing the change in resistance for elements of an array

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